

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|----------|------------------|---------|------------------|
| L1 | 0 | (substrate and (gate with (insulator or dielectric)) and (first with mold) and etch\$3 and (opening or trench or via or mesa or hole or cavity) and (first with metal with gate) and (second with mold) and (secondt with metal with gate) and (work adj function)).CLM. | US-PGPUB | OR | ON | 2005/09/27 17:33 |
| L2 | 0 | (substrate and (gate with (insulator or dielectric)) and (first with mold) and etch\$3 and (opening or trench or via or mesa or hole or cavity) and (first with metal with gate) and (second with mold) and (secondt with metal with gate)).CLM. | US-PGPUB | OR | ON | 2005/09/27 17:33 |
| L3 | 1 | (substrate and (gate with (insulator or dielectric)) and (first with mold) and etch\$3 and (opening or trench or via or mesa or hole or cavity) and (first with metal with gate) and (second with mold) and (second with metal with gate)).CLM. | US-PGPUB | OR | ON | 2005/09/27 17:33 |
| L4 | 1 | (substrate and (gate with (insulator or dielectric)) and (first with mold) and etch\$3 and (opening or trench or via or mesa or hole or cavity) and (first with metal with gate) and (second with mold) and (second with metal with gate) and (work adj function)).CLM. | US-PGPUB | OR | ON | 2005/09/27 17:33 |